

# ABSTRACT

An anti-reflective and anti-static multilayer structure for display device, comprising a glass substrate, and an ITO layer, a first Nb<sub>2</sub>O<sub>5</sub> layer, a first SiO<sub>2</sub> layer, a second Nb<sub>2</sub>O<sub>5</sub> layer and a second SiO<sub>2</sub> layer, which are successively formed on the glass substrate, achieves good film adhesive strength, solidity and enhanced photoreflectance.